

Photon-Absorption Enhancement Factor

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two Advanced Detector Awards, Office of Science, DOE

**ENCLOSURE:
FLAT-PANEL TV**



**3 existing
mass-production
technologies**

**PHOTON→ELECTRON
CONVERSION:
CLASSICAL
PHOTOCATHODE**

**ELECTRON DETECTION:
SEMICONDUCTOR
Scintillator + Geiger-MODE
AVALANCHE
DIODE
‘Light Amplifier’**

**ENCLOSURE:
FLAT-PANEL TV**



**MAJOR
MODIFICATIONS
(will show
tomorrow)**

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**LOOKIN
FORWARD
FOR
IMPROVEMENTS**

**ENCLOSURE:
FLAT-PANEL TV**



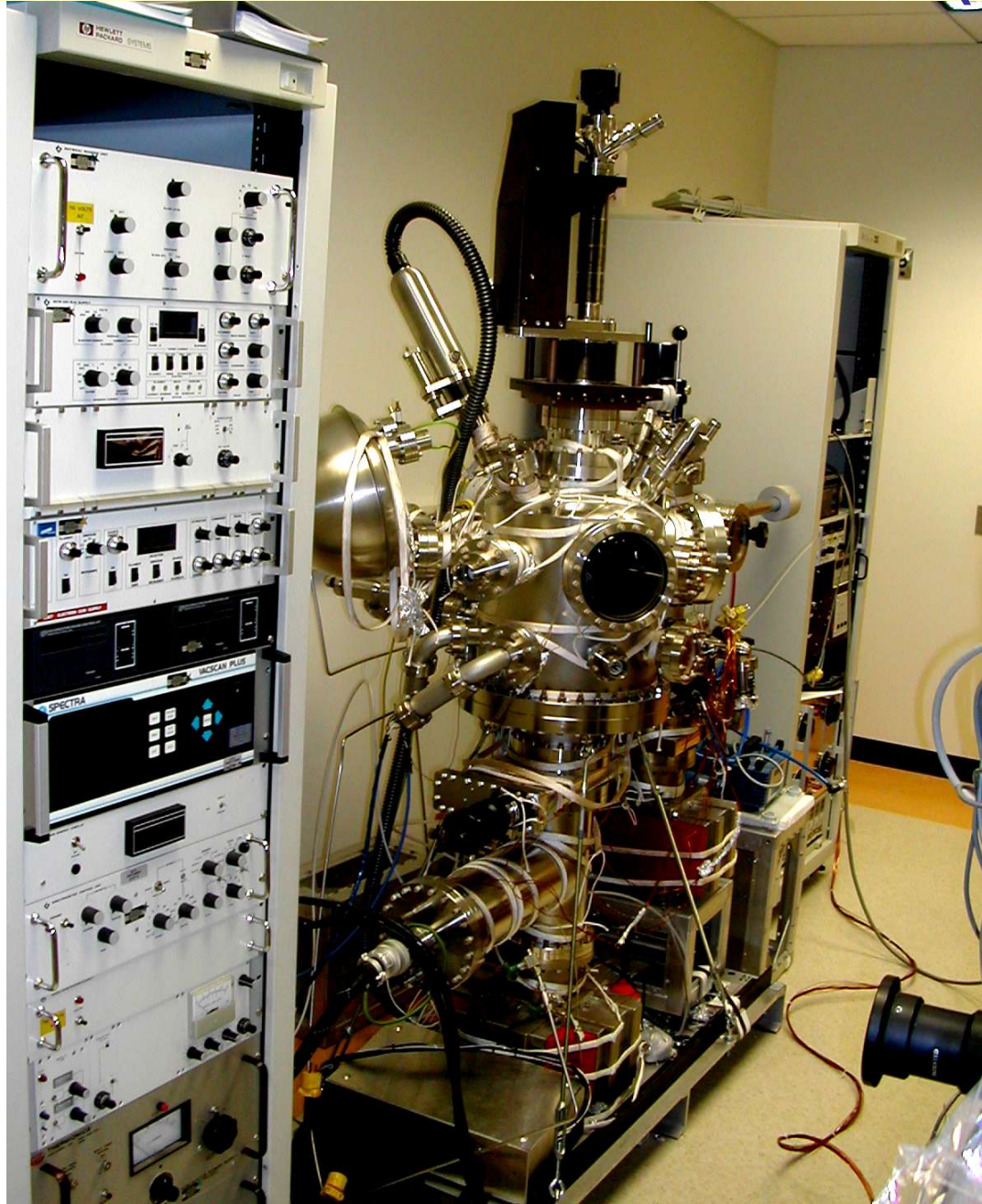
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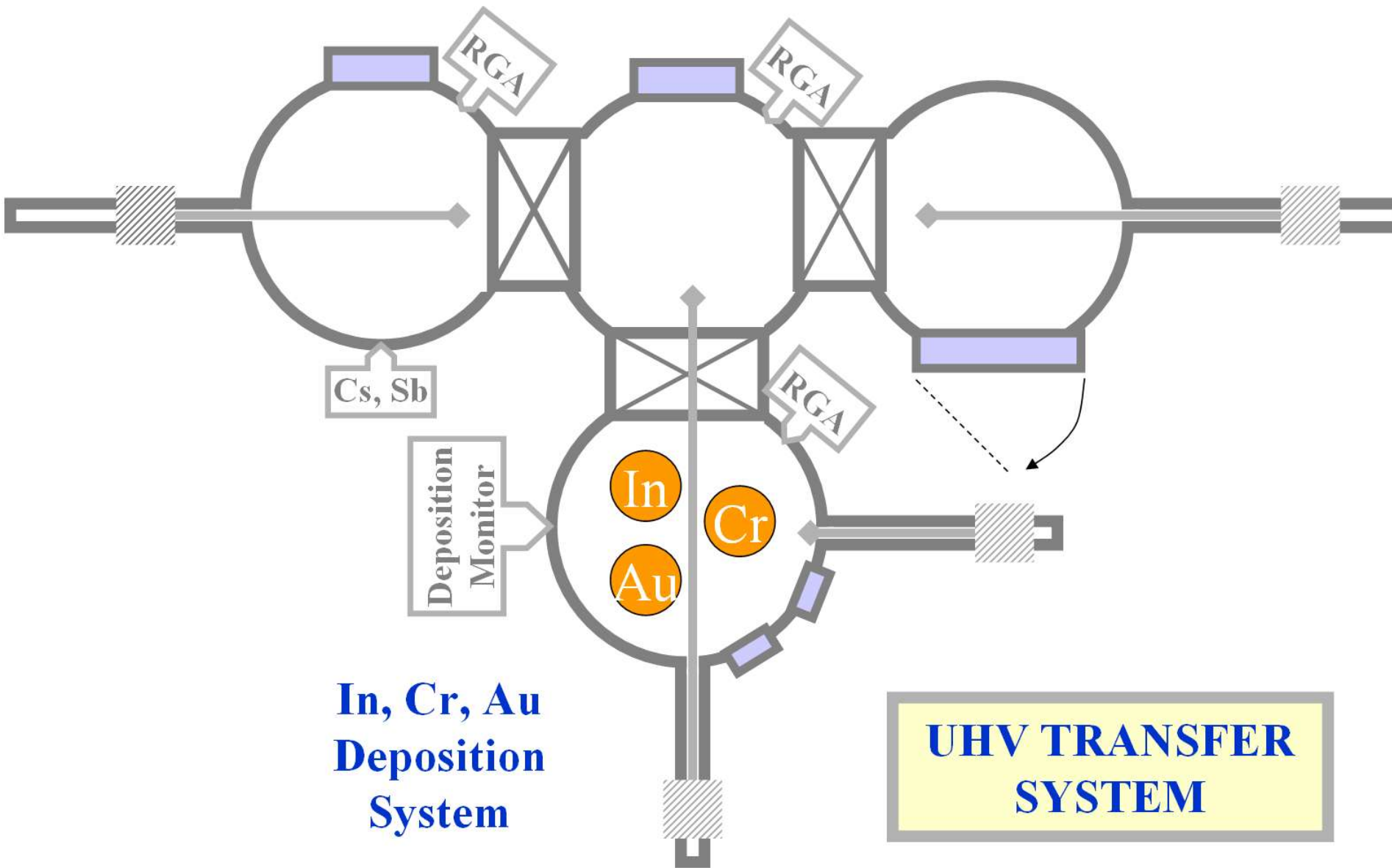
DIAGNOSTIC TOOL – NOT USED (YET)



**Photocathode
Deposition
Chamber**

**Sealing
Chamber**

**Load-Lock
Chamber**



Cs, Sb

RGA

RGA

RGA

Deposition
Monitor

In

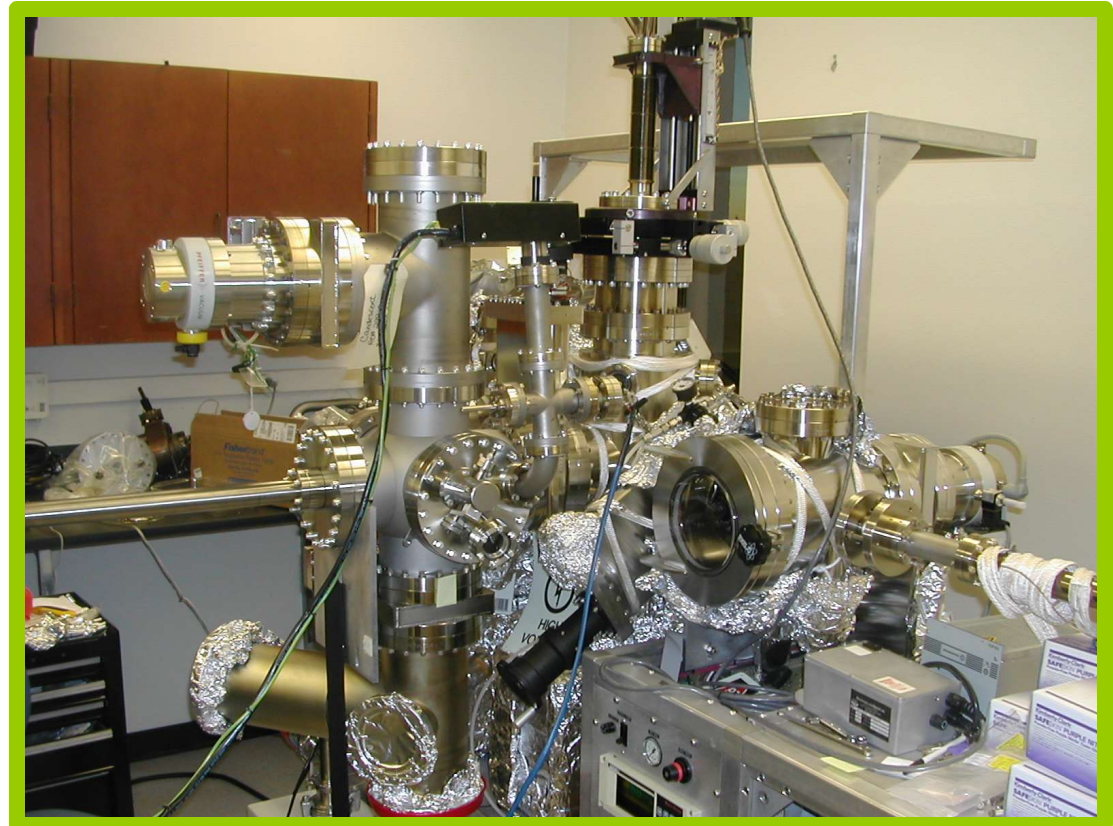
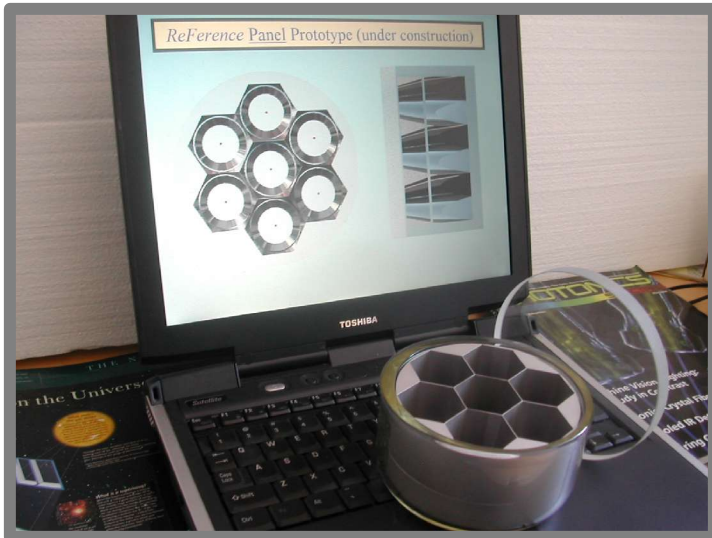
Cr

Au

**In, Cr, Au
Deposition
System**

**UHV TRANSFER
SYSTEM**

7-pixel 5-inch ReFERENCE Flat-Panel Prototype



UHV Transfer System :

- **Photocathode deposition**
- **Indium/Au/Cr deposition**
- **Vacuum sealing**



Lasers for
Active
Mirror
Control

SUPER-EFFICIENT CAMERA



CAMERA

A METHOD TO INCREASE THE QE: COAT WINDOW WITH A LAQUER LOADED WITH WLS AND USING A FAST EVAPORATING SOLVENT -> FORMS FROSTED WINDOW SURFACE LAYER

- ◆ Simple way of producing a scattering layer
 - Increase the quantity of Paraloid B-72 by a factor 2-3
 - Dip the PMT 2-3 times (waiting 5 min.)

→ Milky layer easy to be removed



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The camera

- ◆ Matrix of 577 PMTs
- Two sections:
 - ◆ Inner part: 0.1° PMTs
 - ◆ Outer part: 0.2° PMTs

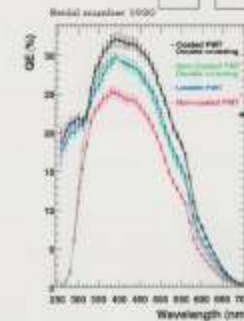
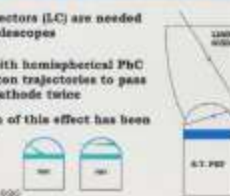
Plate of Winston cones → Active camera area ~100%



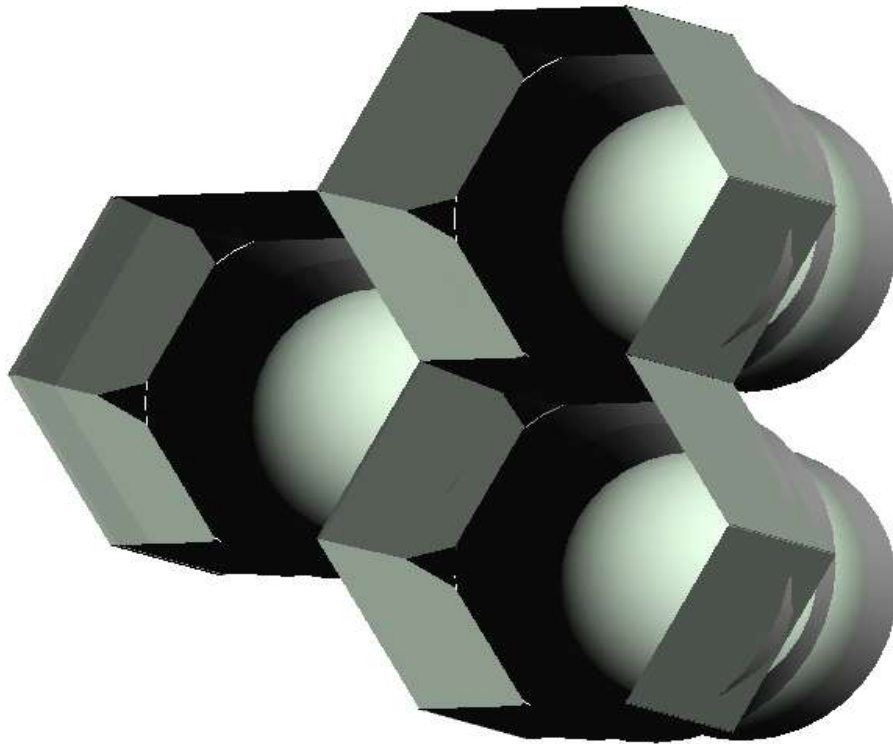
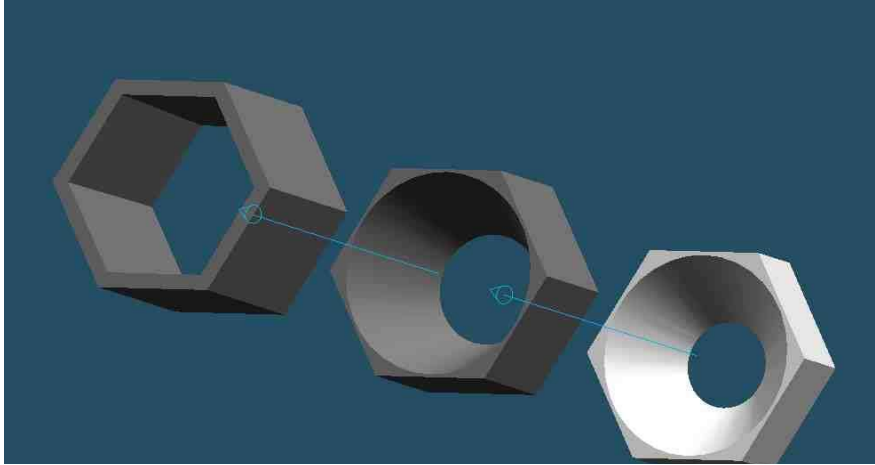
CAMERA

4- INCREASE IN THE QE BY ALLOWING LIGHT TO CROSS THE PhC TWICE IN A HEMISPHERICAL PMT

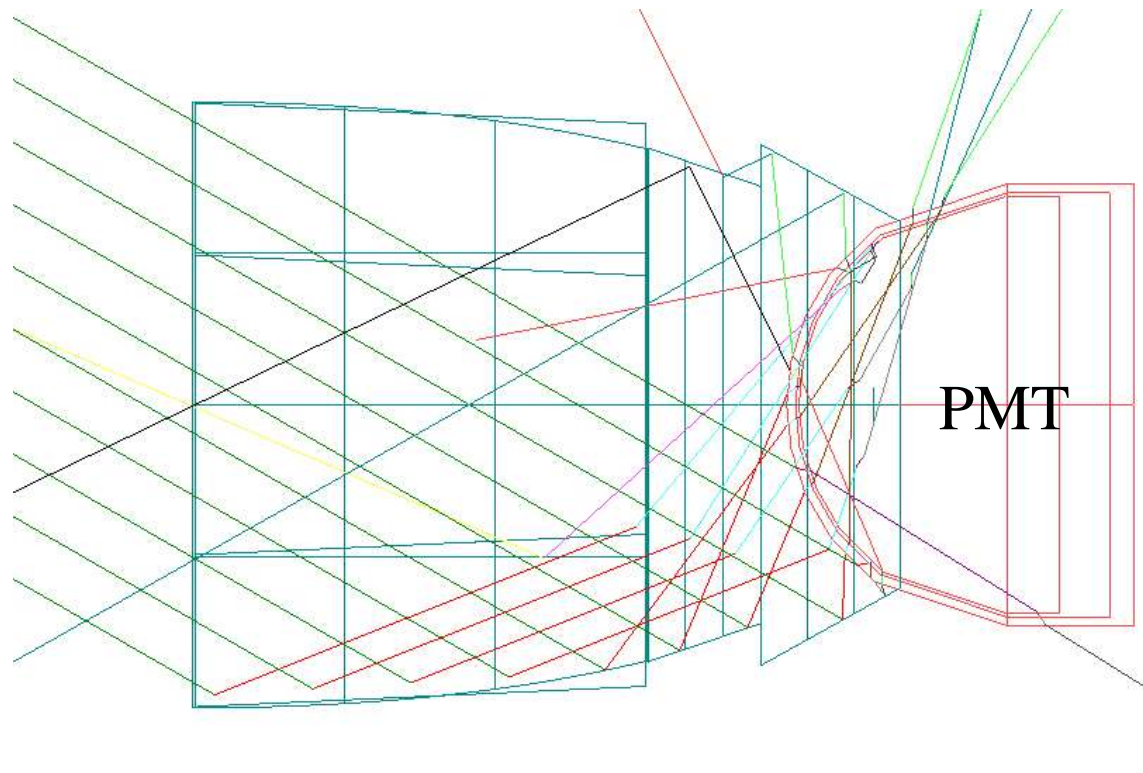
- ◆ Light Collectors (LC) are needed in IACT telescopes
- ◆ LC-PMT with hemispherical PhC allows photon trajectories to pass the photocathode twice
- ◆ Estimation of this effect has been measured



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Maximizing Double-Hits in a PMT

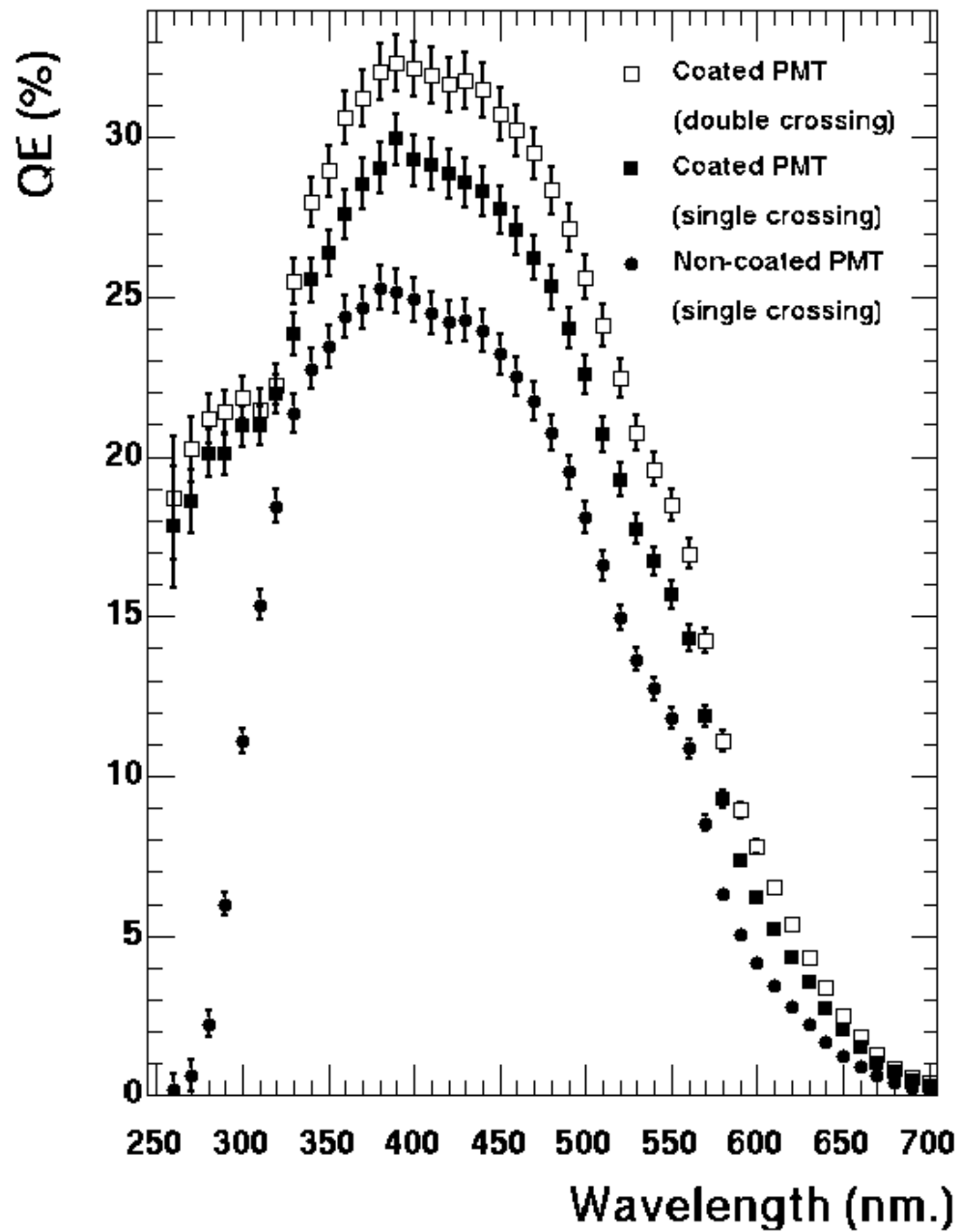


Not yet optimized for the milky PMT coating



Significant additional improvements to come





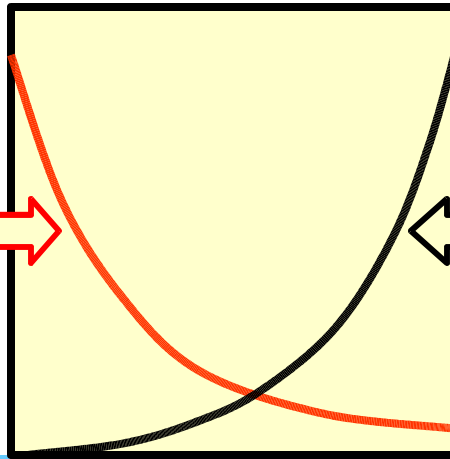
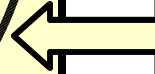
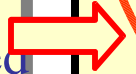
Photon Absorption
(Electron 'Creation')

e.g. in S-20

40% ph. (400 nm) are absorbed

in a **30 nm** thick

photocathode



Probability for an
electron to reach
the vacuum
surface

*Random Walk - mainly
electron-imperfection
scattering
(less e-e and e-phonon)*

e.g. scattering length in S-20
~25 nm

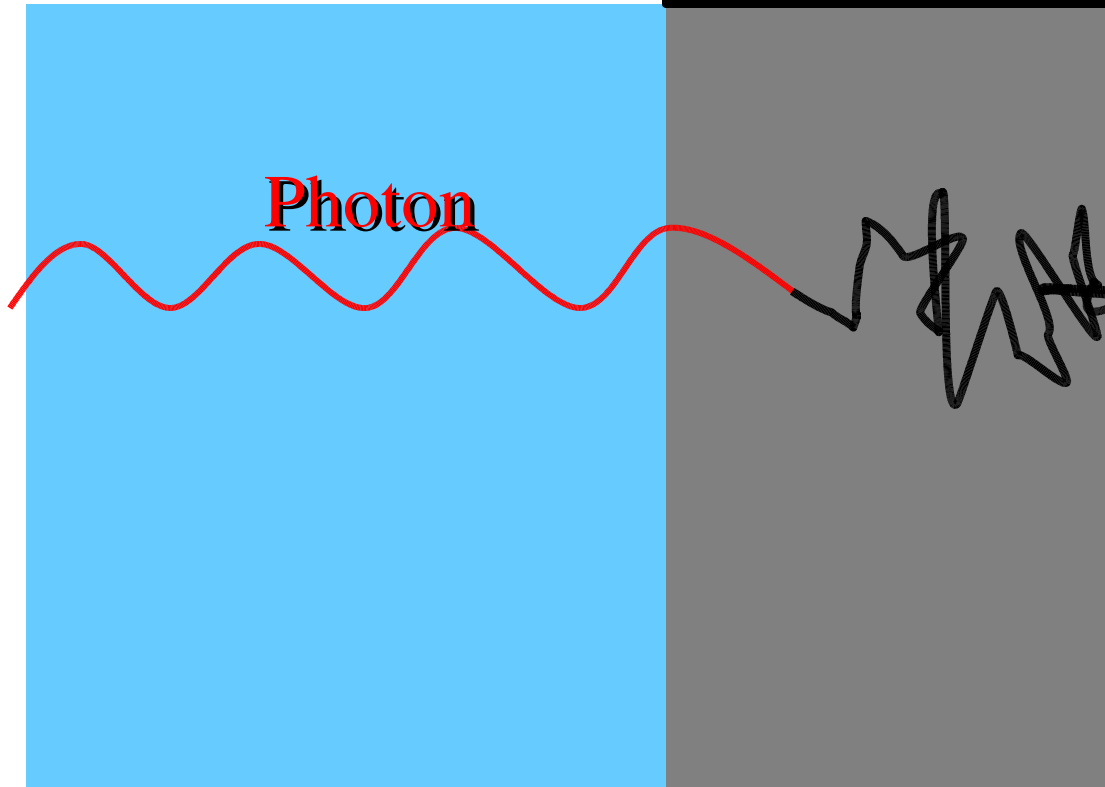


Photo-Electron

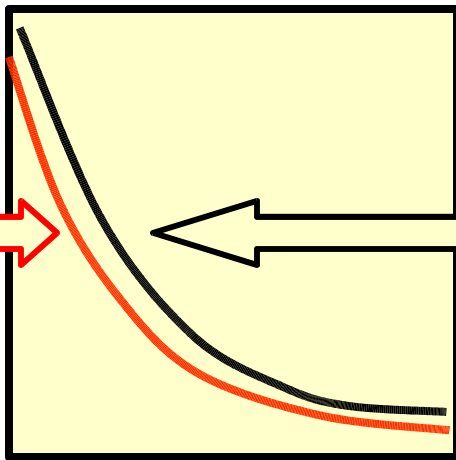
Therefore:
QE ~ 10-20%

Glass Window

Photocathode

Vacuum

Photon Absorption
(Electron Creation)

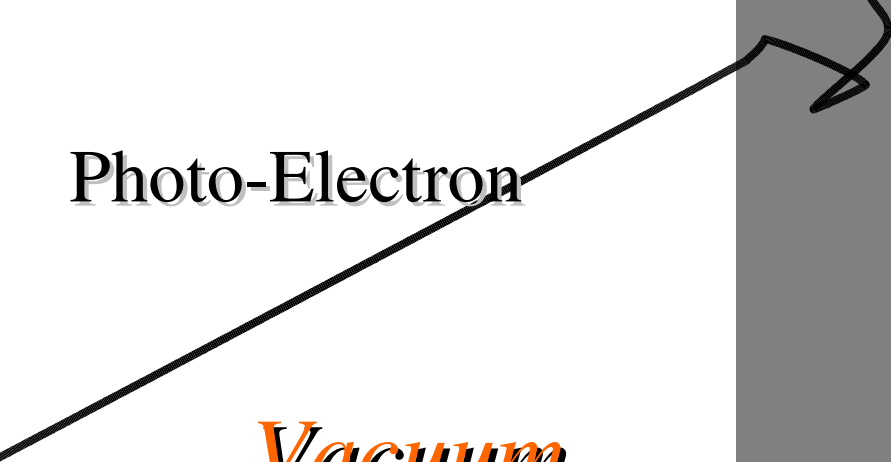


Probability for an
Electron to Reach
the Vacuum
Surface
(Random Walk)



Photon

Photo-Electron



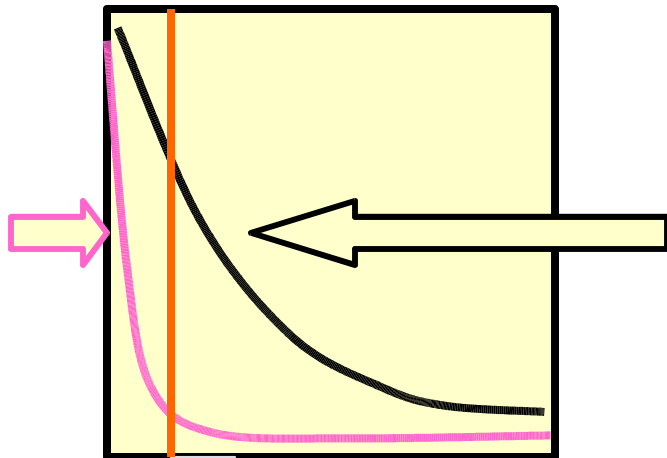
Vacuum

(e.g. Substrate,
Reflector,...)

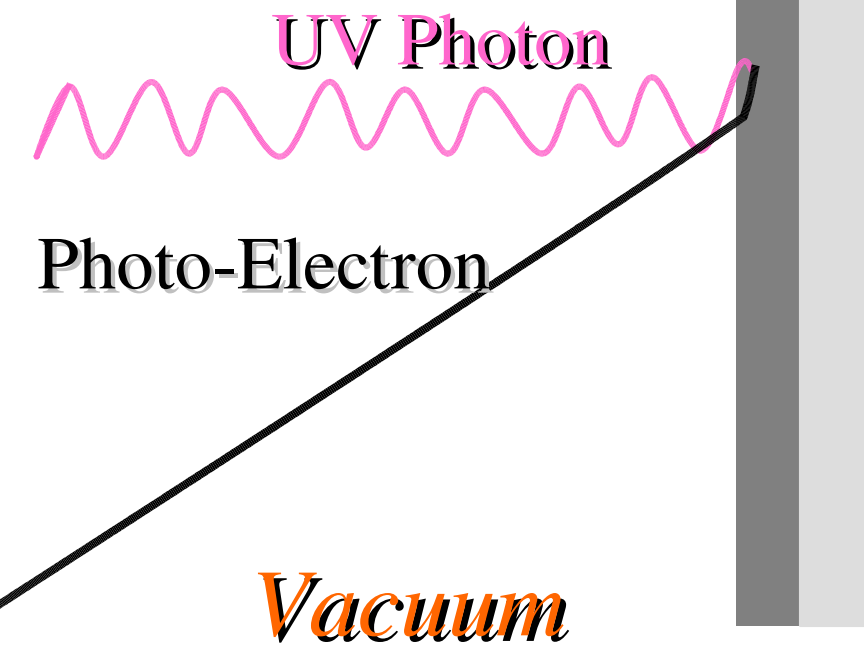
& LOWER
PRODUCTION
COST !

Photocathode

UV
Photon Absorption
(Electron Creation)
Mostly @ Surface



Probability for an
Electron to Reach
the Vacuum
Surface
(Random Walk)

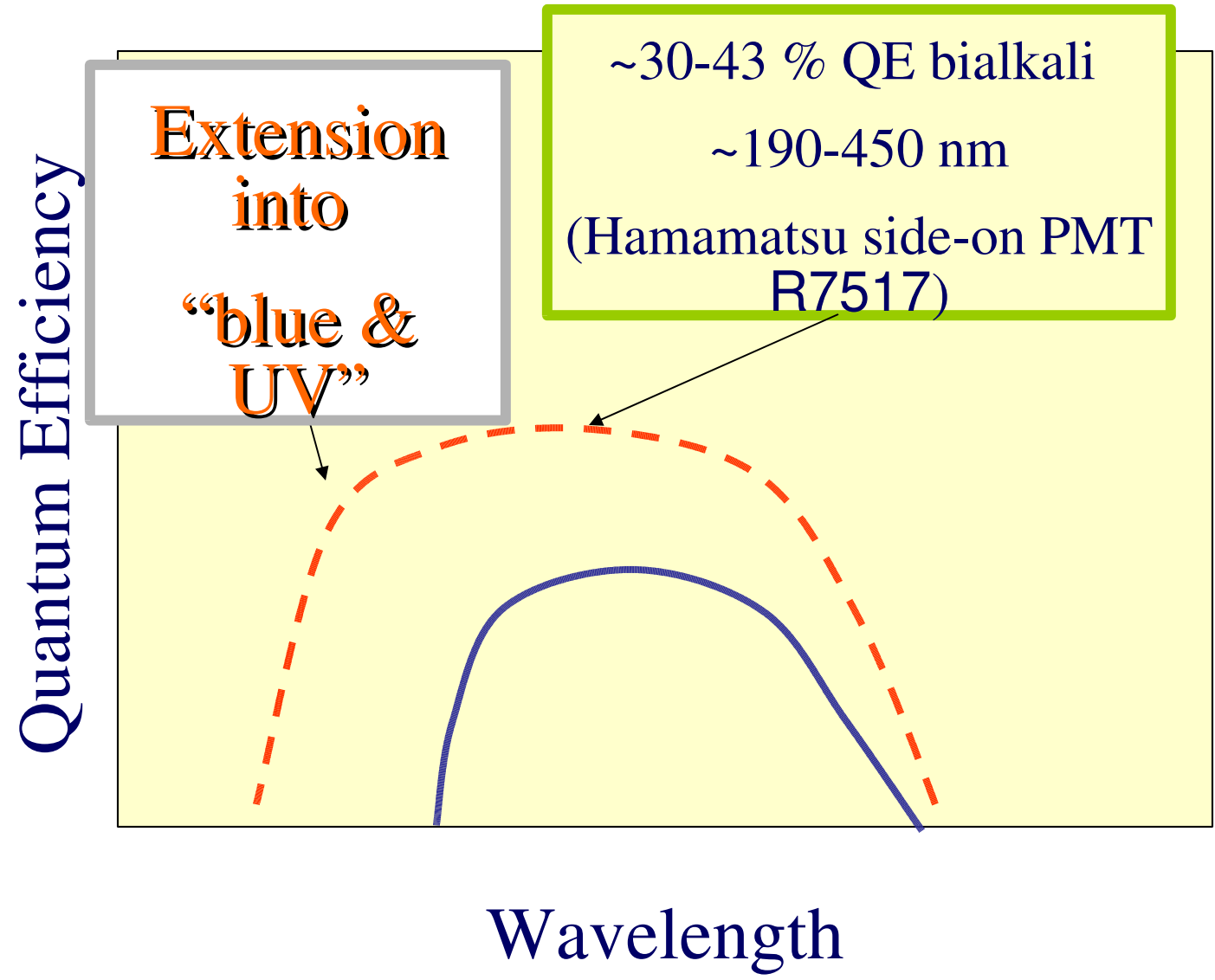


Thin Photocathode
on a Reflector,
Interference, Multi-
layer Systems

Westinghouse, RCA, ITT
~1963-1975

Photocathode

Reflection Mode vs. Transmission Mode



HAMAMATSU

PRELIMINARY DATA
NOV. 1998

PHOTOMULTIPLIER TUBE R7517

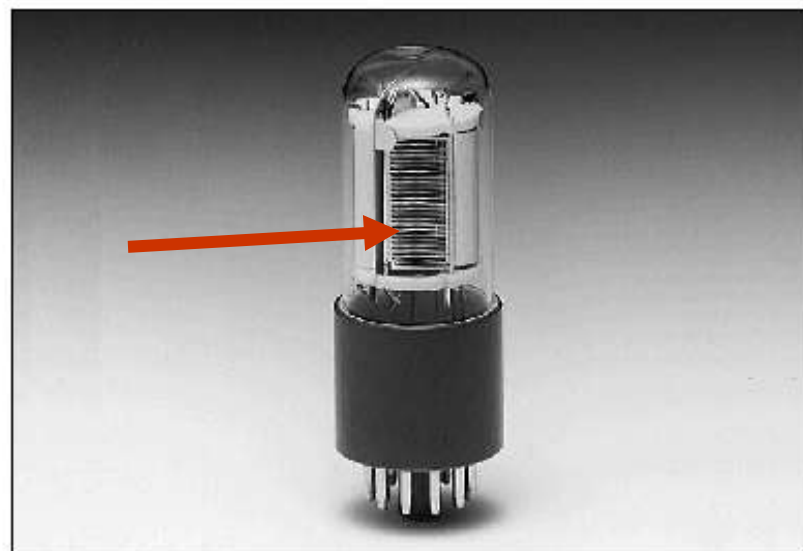
High Q.E., Bialkali Photocathode 28mm (1-1/8 Inch) Diameter, 9-Stage, Side-On Type

FEATURES

- Spectral Response..... 185 to 760 nm
- High Cathode Sensitivity
 - Luminous 160 $\mu\text{A}/\text{lm}$ Typ.
 - Radiant at 420nm 105 mA/W Typ.
 - Quantum Efficiency at 220nm 40% Typ.
- High Anode Sensitivity (at 1000V)
 - Luminous 1600A/lm Typ.
 - Radiant at 420nm 10.5×10^5 A/W Typ.

APPLICATIONS

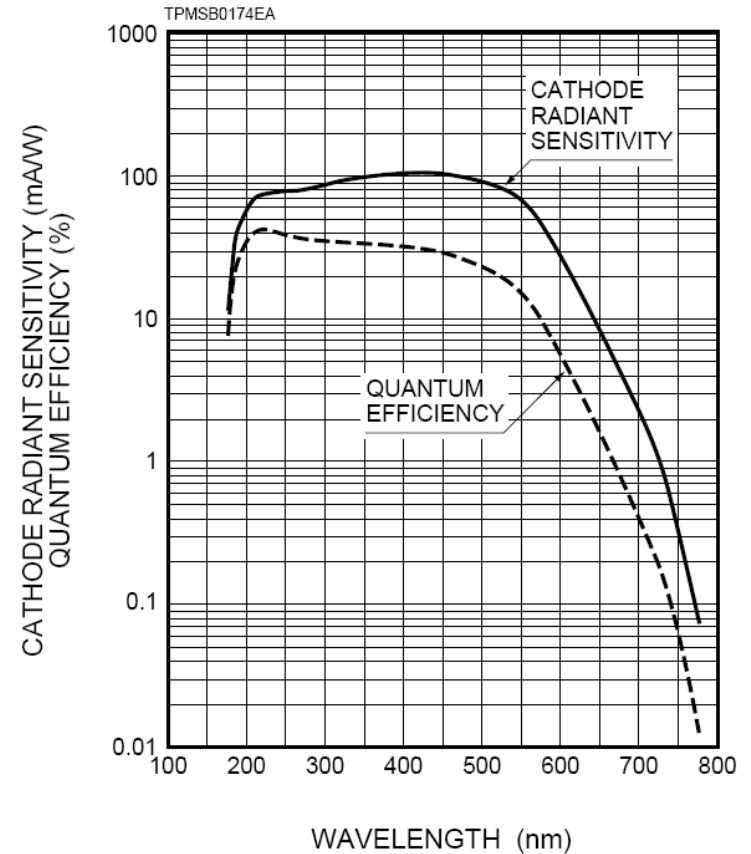
- Fluorescence Spectrophotometers
- Fluorescence Immuno Assay
- SO₂ Monitor (UV Fluorescence)



GENERAL

Parameter	Description	Unit
Spectral Response	185 to 760	nm
Wavelength of Maximum Response	420	nm
Photocathode Material	Bialkali	—
Minimum Effective Area	8 × 24	mm
Window Material	UV glass	—
Dynode		
Secondary Emitting Surface	Bialkali	—
Structure	Circular-cage	—
Number of Stages	9	—
Direct Interelectrode Capacitances		
Anode to Last Dynode	4	pF
Anode to All Other Electrodes	6	pF
Base	11-pin base JEDEC No. B11-88	—
Weight	45	g
Suitable Socket	E678-11A (option)	—
Suitable Socket Assembly	E717-21(option)	—

Figure 1: Typical Spectral Response



TRANSMISSION PC

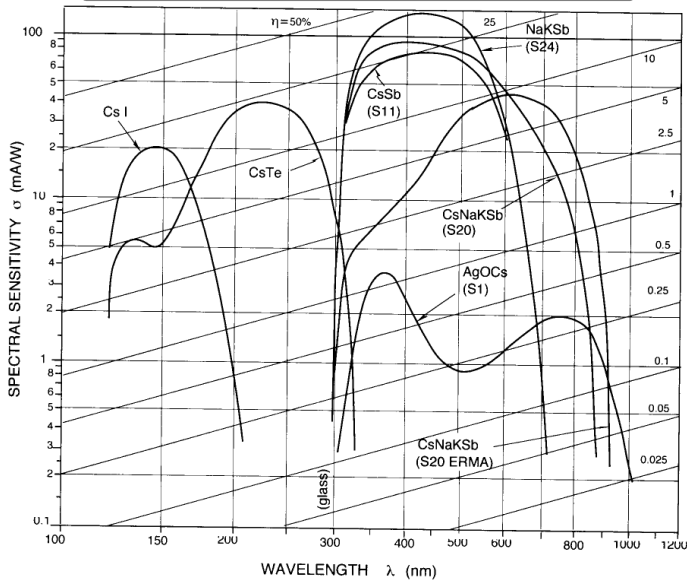


Figure 2-7 Spectral sensitivity vs. wavelength of transmission photocathodes (left, solar-blind responses with magnesium fluoride window; right, common photocathodes with glass window). In parentheses, the standard international EIA designation is shown

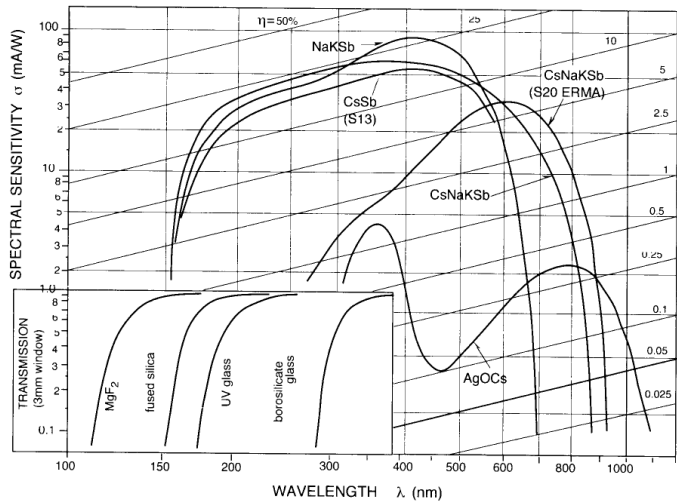


Figure 2-8 Spectral sensitivity vs. wavelength of transmission photocathodes with several UV-grade windows. Insert shows the transmission of a 3-mm thick window

REFLECTION PC

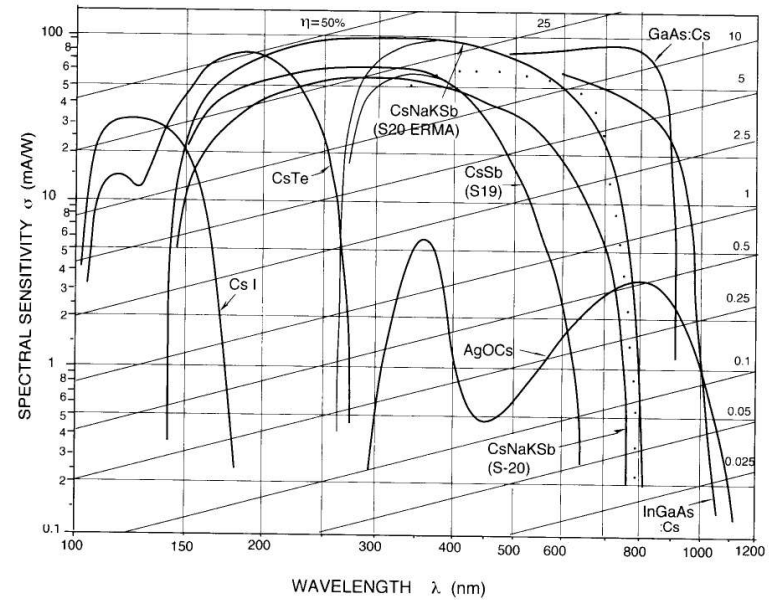


Figure 2-9 Spectral sensitivity vs. wavelength of typical reflection photocathodes. Note that σ is consistently larger than in corresponding transmission photocathodes. Points are simulation results for CsNaKSb, following Eq.(2.13)

Absorption of optical power in an S-20 photocathode

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Abstract

By considering a monochromatic plane wave obliquely incident upon a planar layer of S-20 photocathode material, deposited upon a non-absorbing glass substrate, the distribution of optical power absorbed within the layer can be resolved. This is important to the question of photocathode efficiency, as the absorbed light excites photoelectrons within the photocathode which then may pass from the photocathode into the vacuum of the photomultiplier tube and be collected and multiplied. The calculation uses the measured complex permittivity of an extended red S-20 photocathode in the wavelength range, 375–900 nm. The results show that thin film effects are important within the photocathode, as they give rise to interesting power absorption profiles. This information is invaluable in predicting optimum photocathode thickness for wavelength selective applications. Electromagnetic waves that are obliquely incident upon the photocathode are also considered in both transverse electric and transverse magnetic polarizations.

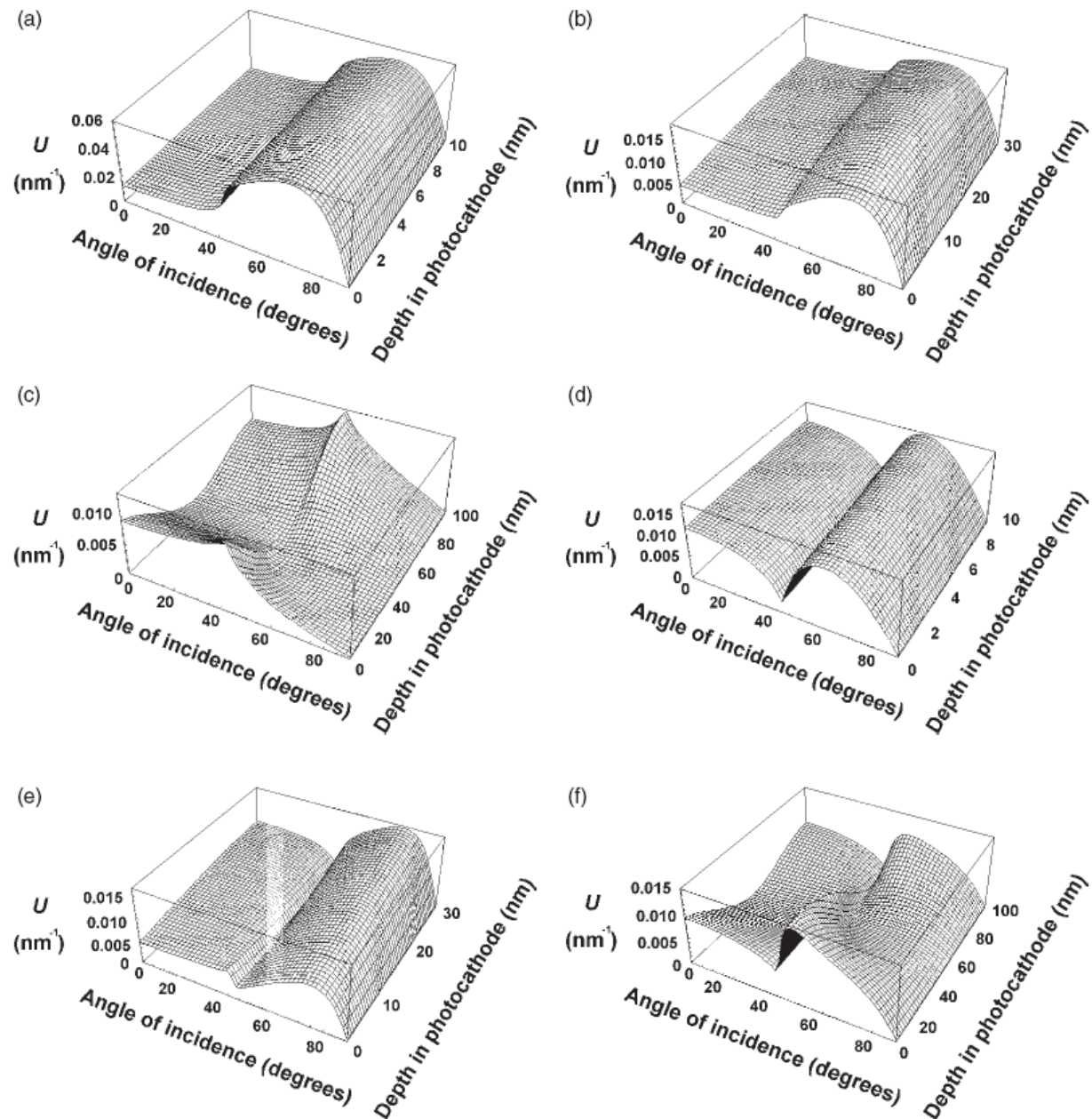
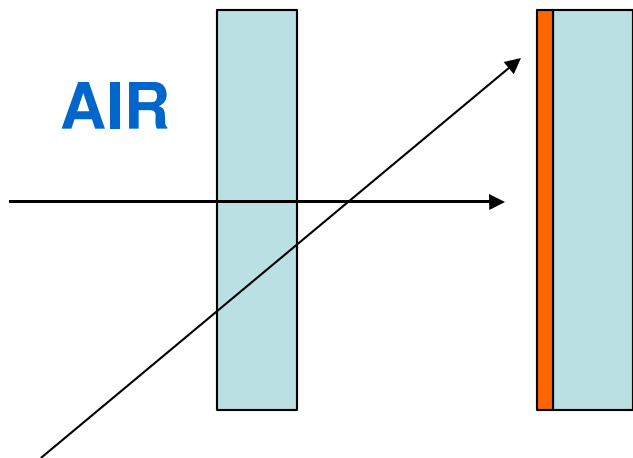


Figure 6. Power profile versus angle of incidence and depth in photocathode. The S-20 photocathode is (a) 10 nm, (b) 30 nm and (c) 100 nm thick and is illuminated by 600 nm TE polarized light. The S-20 photocathode is (d) 10 nm, (e) 30 nm and (f) 100 nm thick and is illuminated by 600 nm TM polarized light.

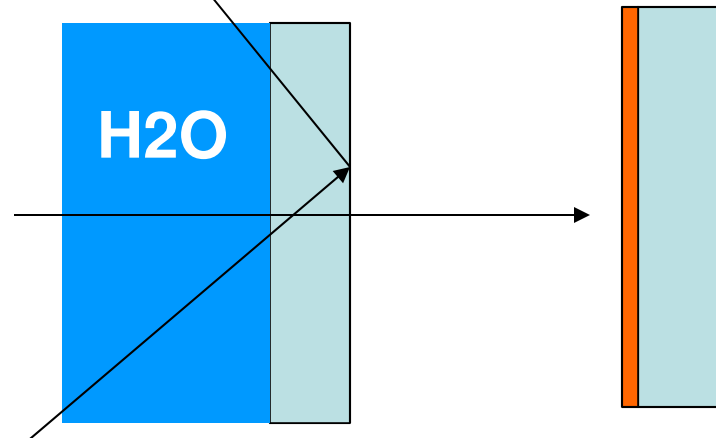
REFLECTION-MODE PHOTOCATHODES

GOOD - air



Gamma-ray astronomy –
Atmospheric Cherenkov
Telescopes

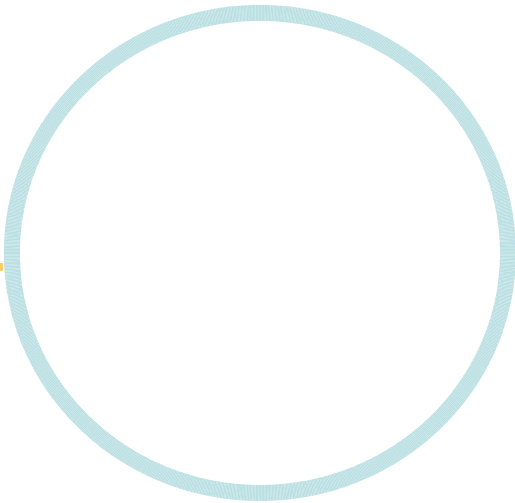
WORSE – dense
media
for larger incidence
angles



- Water Cherenkov – neutrinos etc.
- Liquid scintillator
- Plastic, crystal scintillator



Mr.



&

Mrs.



Mass production
High performance